# DEFECTS IN CRYSTALS

- Point defects
- Line defects
- ☐ Surface Imperfections



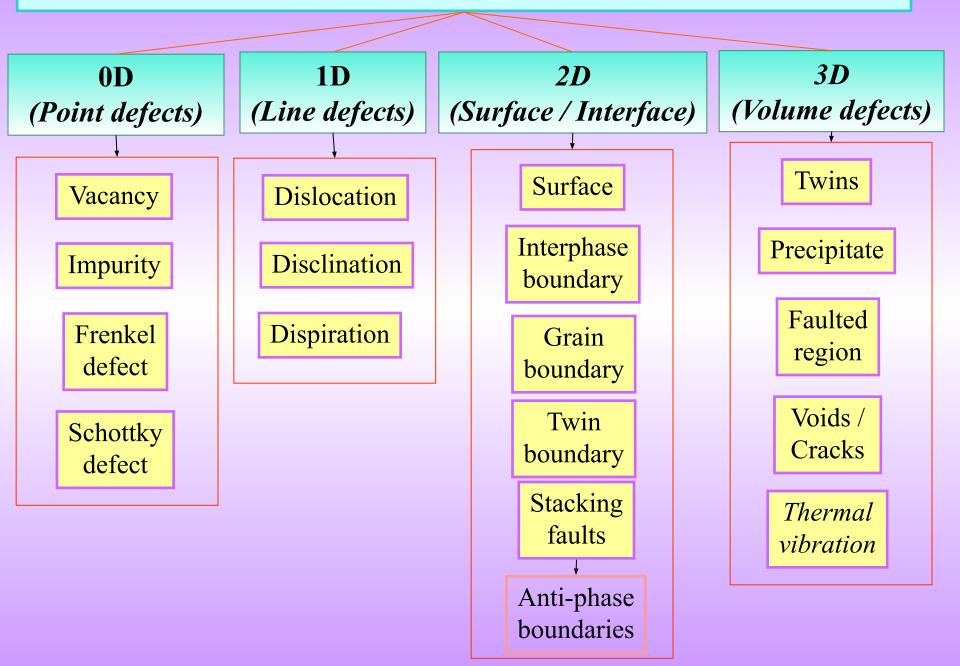
Structure sensitive

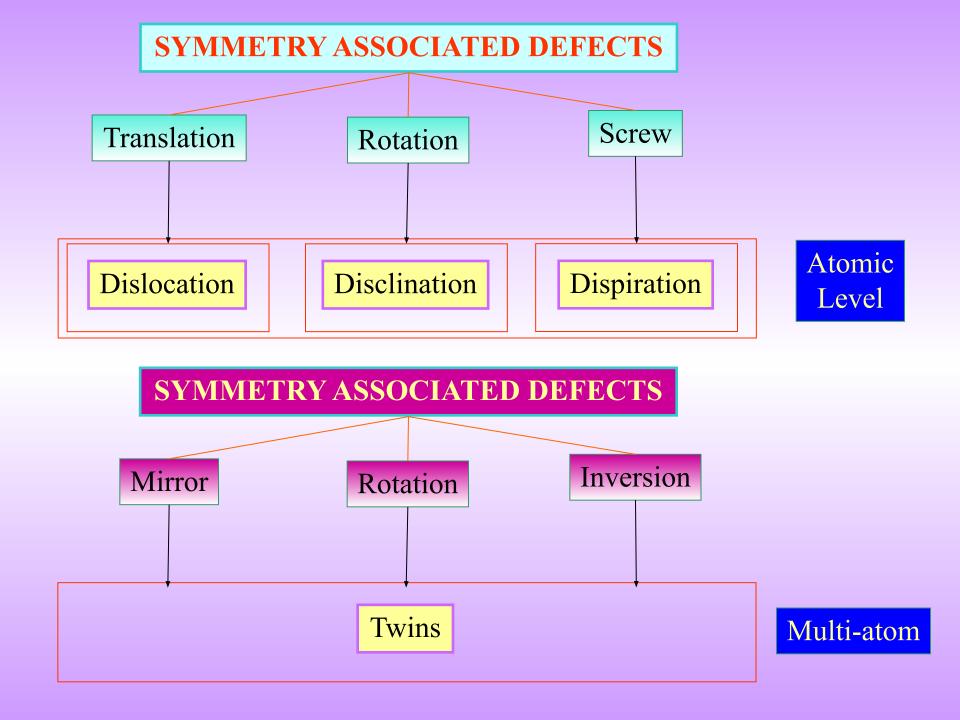
E.g. Yield stress, Fracture toughness

Structure Insensitive

E.g. Density, elastic modulus

#### **CLASSIFICATION OF DEFECTS BASED ON DIMENSIONALITY**



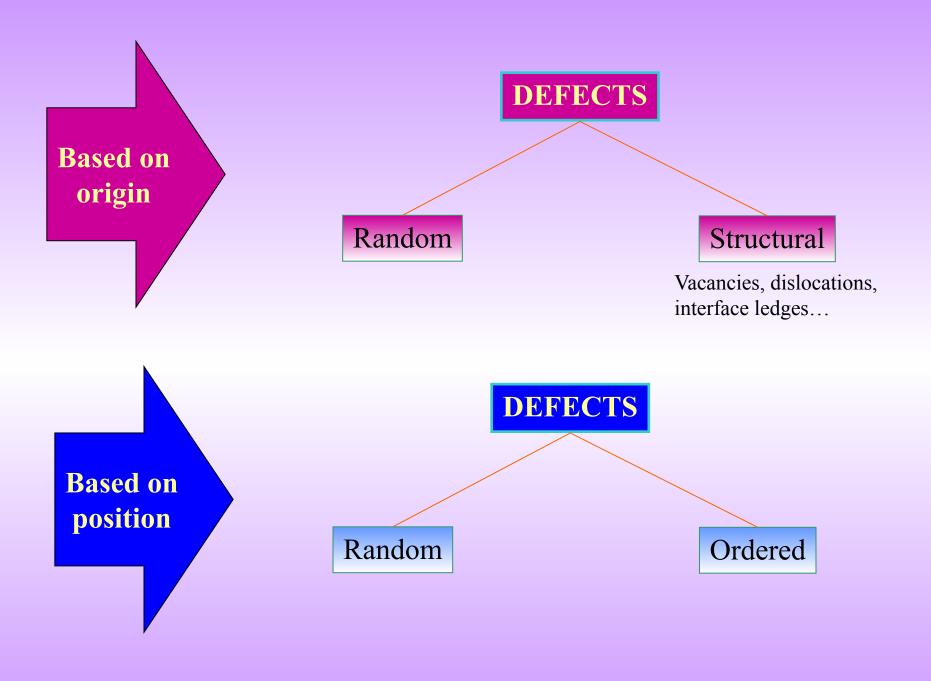




**DEFECTS** 

Topological

Non-topological



# THE ENTITY IN QUESTION

**GEOMETRICAL** 

E.g. atoms, clusters etc.

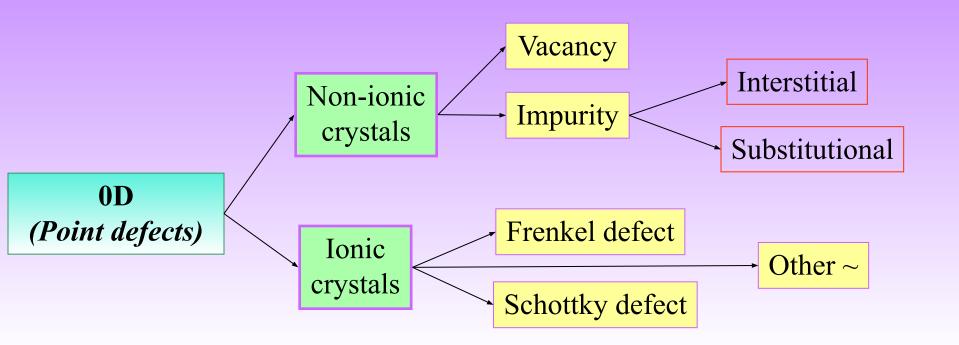
**PHYSICAL** 

E.g. spin, magnetic moment

# THE OPERATION DEFINING A DEFECT CANNOT BE A SYMMETRY OPERATION OF THE CRYSTAL

A DEFECT "ASSOCIATED" WITH A SYMMETRY OPERATION OF THE CRYSTAL

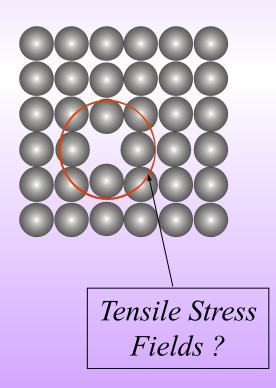
**☐ TOPOLOGICAL DEFECT** 

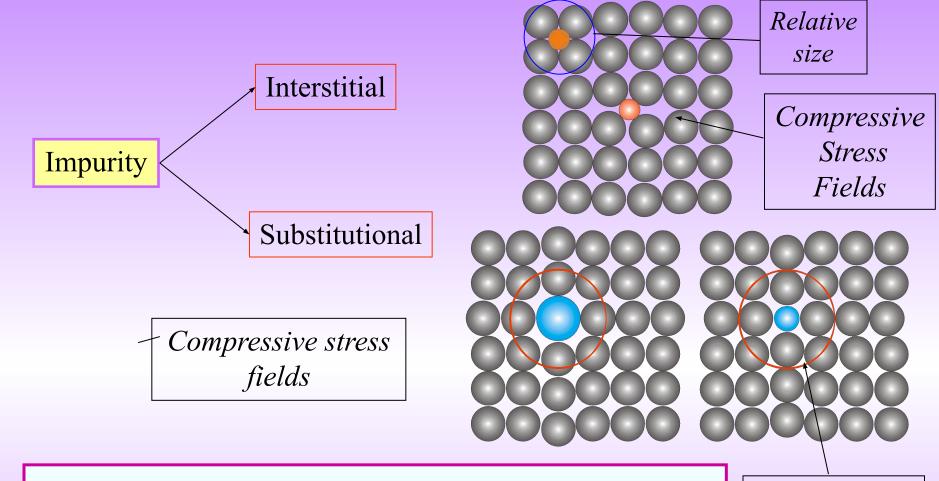


Imperfect point-like regions in the crystal about the size of 1-2 atomic diameters

## Vacancy

- Missing atom from an atomic site
- Atoms around the vacancy displaced
- Tensile stress field produced in the vicinity





#### SUBSTITUTIONAL IMPURITY

- · Foreign atom replacing the parent atom in the crystal
- · E.g. Cu sitting in the lattice site of FCC-Ni

#### INTERSTITIAL IMPURITY

- · Foreign atom sitting in the void of a crystal
- · E.g. C sitting in the octahedral void in HT FCC-Fe

Tensile Stress Fields

## Interstitial C sitting in the octahedral void in HT FCC-Fe

$$r_{\text{Octahedral void}} / r_{\text{FCC atom}} = 0.414$$

$$r_{\text{Fe-FCC}} = 1.29 \text{ Å}$$
  $\Rightarrow$   $r_{\text{Octahedral void}} = 0.414 \text{ x } 1.29 = 0.53 \text{ Å}$ 

$$r_{\rm C} = 0.71 \text{ Å}$$

- $\Rightarrow$  Compressive strains around the C atom
- Solubility limited to 2 wt% (9.3 at%)

## Interstitial C sitting in the octahedral void in LT BCC-Fe

- $r_{\text{Tetrahedral void}} / r_{\text{BCC atom}} = 0.29 \cdot r_{\text{C}} = 0.71 \text{ Å}$
- $r_{\text{Fe-BCC}} = 1.258 \text{ Å} \implies r_{\text{Tetrahedral void}} = 0.29 \text{ x } 1.258 = 0.364 \text{ Å}$
- □ But C sits in smaller octahedral void- displaces fewer atoms
- $\Rightarrow$  Severe compressive strains around the C atom
- Solubility limited to 0.008 wt% (0.037 at%)

#### ENTHALPY OF FORMATION OF VACANCIES

- Formation of a vacancy leads to missing bonds and distortion of the lattice
- The potential energy (Enthalpy) of the system increases
- Work required for the formaion of a point defect  $\rightarrow$  Enthalpy of formation ( $\Delta H_f$ ) [kJ/mol or eV / defect]
- Though it costs energy to form a vacancy its formation leads to increase in configurational entropy
  - ⇒ above zero Kelvin there is an equilibrium number of vacancies

Crystal	Kr	Cd	Pb	Zn	Mg	Al	Ag	Cu	Ni
kJ / mol	7.7	38	48	49	56	68	106	120	168
eV / vacancy	0.08	0.39	0.5	0.51	0.58	0.70	1.1	1.24	1.74

- $\perp$  Let n be the number of vacancies, N the number of sites in the lattice
  - Assume that concentration of vacancies is small i.e.  $n/N \ll 1$ 
    - ⇒ the interaction between vacancies can be ignored
    - $\Rightarrow \Delta H_{\text{formation}}$  (n vacancies) = n .  $\Delta H_{\text{formation}}$  (1 vacancy)
- ightharpoonup Let  $\Delta H_f$  be the enthalpy of formation of 1 mole of vacancies

$$\Delta G = \Delta H - T \Delta S$$

$$\Delta S = \Delta S_{thermal} + \Delta S_{configurational}$$

 $\Delta G$  (putting n vacancies) =  $n\Delta H_f - T \Delta S_{config}$ 

Larger contribution

$$\frac{\partial \Delta G}{\partial n} = \Delta H_f + n \frac{\partial \Delta H_f}{\partial n} - T \frac{\partial \Delta S_{config}}{\partial n}$$

$$\frac{\partial \Delta S_{config}}{\partial n} = k \ln \left( \frac{N - n}{n} \right)$$

For minimum 
$$\longrightarrow \frac{\partial \Delta G}{\partial n} = 0$$

$$\Rightarrow$$

$$\frac{\Delta H_f}{kT} = \ln\left(\frac{N-n}{n}\right)$$

Assuming  $n \ll N$ 

Considering only configurational entropy

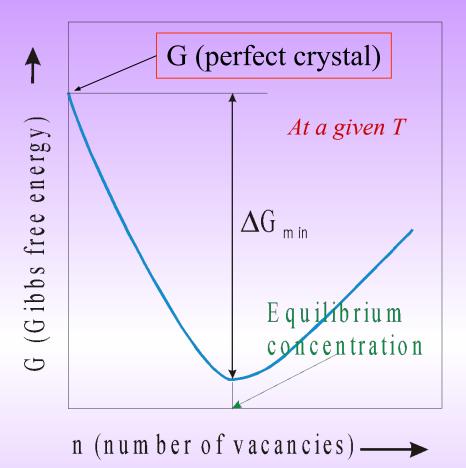
$$\frac{n}{N} = \exp\left(-\frac{\Delta H_f}{kT}\right)$$

User R instead of k if  $\Delta H_f$  is in J/mole

$$\Delta S = \Delta S_{\text{thermal}}^2 + \Delta S_{\text{configurational}}$$

$$\frac{n}{N} = \exp\left(\frac{1}{k} \frac{\partial \Delta S_{thermal}}{\partial n}\right) \exp\left(-\frac{\Delta H_f}{kT}\right)$$

Independent of temperature, value of ~3



T (°C)	n/N				
500	$1 \times 10^{-10}$				
1000	$1 \times 10^{-5}$				
1500	5 x 10 <sup>-4</sup>				
2000	$3 \times 10^{-3}$				
$\Delta H_f = 1 \text{ eV/vacancy}$					
$= 0.16 \times 10^{-18}$					
J/vacancy					

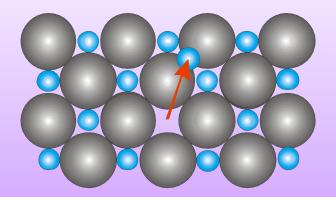
Certain equilibrium number of vacancies are preferred at T > 0K

# Ionic Crystals

Overall electrical neutrality has to be maintained

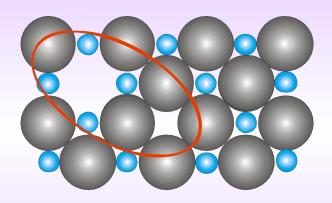
#### Frenkel defect

- Cation (being smaller get displaced to interstitial voids
- E.g. AgI, CaF<sub>2</sub>



# Schottky defect

- Pair of anion and cation vacancies
- E.g. Alkali halides

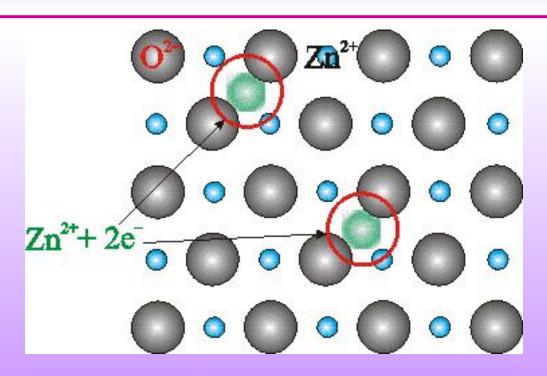


#### Other defects due to charge balance

If  $Cd^{2+}$  replaces  $Na^{+} \rightarrow$  one cation vacancy is created

## Defects due to off stiochiometry

- ZnO heated in Zn vapour  $\rightarrow$  Zn<sub>y</sub>O (y > 1)
- The excess cations occupy interstitial voids
- The electrons (2e<sup>-</sup>) released stay associated to the interstitial cation



- FeO heated in oxygen atmosphere  $\rightarrow$  Fe<sub>x</sub>O (x < 1)
- Vacant cation sites are present
- Charge is compensated by conversion of ferrous to ferric ion:

$$Fe^{2+} \rightarrow Fe^{3+} + e^{-}$$

For every vacancy (of Fe cation) two ferrous ions are converted to ferric ions → provides the 2 electrons required by excess oxygen

